IN THE DRAWINGS:

The attached sheets of drawings include changes to Figs. 2, 3, 6, 9D, 12, 13A and 13B to correct minor errors in these figures.

Attachment: Replacement Sheets (being submitted with corrected formal drawings)

Annotated Sheets Showing Changes

REMARKS

Applicant is merely amending the figures herein to correct minor errors in the figures, as follows:

In Fig. 2, line S4 has been amended to show "(4,4)" and not "(4,3)" (see e.g. page 5, lns. 23-24 of the specification).

In Fig. 3, nodes are being added for (2,640) and (480,640).

In Fig. 6, nodes are being added for (2, n) and (m,n).

In Fig. 9D, "1028a" has been amended to "6028a" (see page 22, ln. 6).

In Fig. 12, "218" has been amended to "818" (see page 27, ln. 22).

In Fig. 13A, the spelling of "impurity" has been corrected.

In Fig. 13B, 4104 has been amended to recite "benzocyclobutene(BCB)" (see page 29, ln. 17).

Hence, no new matter is being added. Therefore, it is respectfully requested that this amendment be entered.

If any fee is due for this amendment, please charge our deposit account 50/1039.

Favorable consideration is earnestly solicited.

Respectfully submitted,

Mark J. Murphy

Registration No. 34,225

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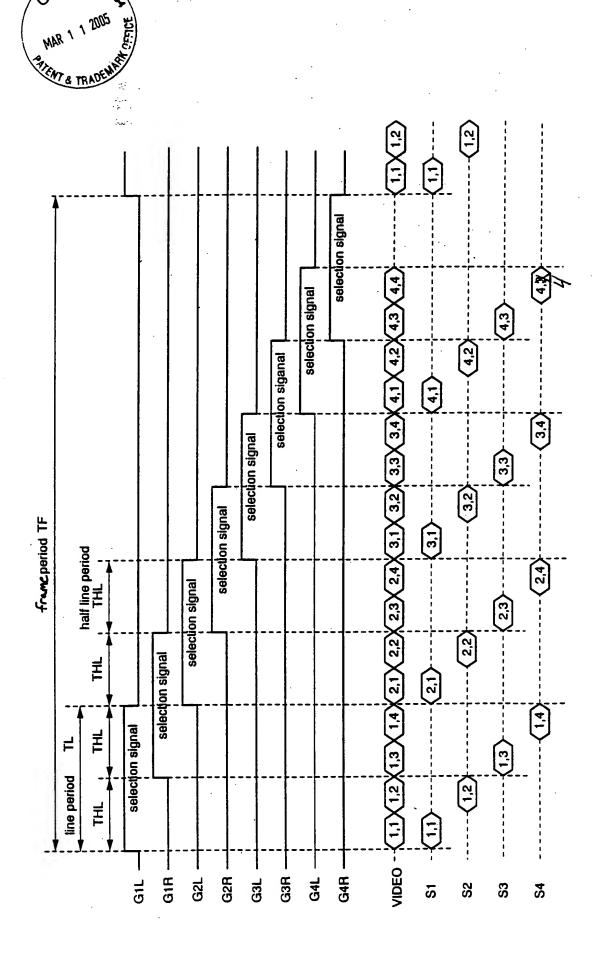
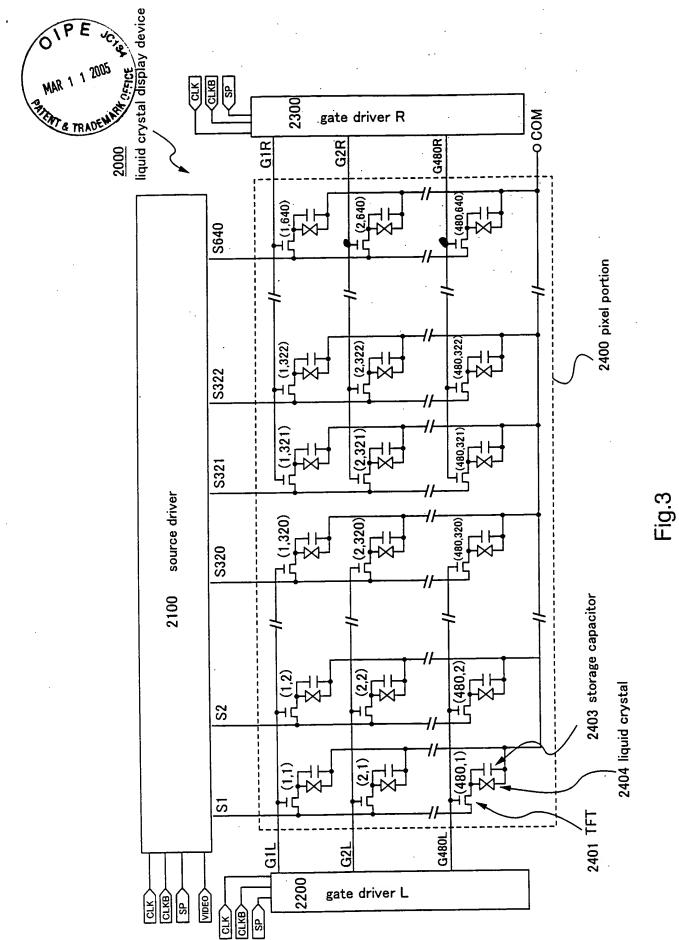


Fig.2



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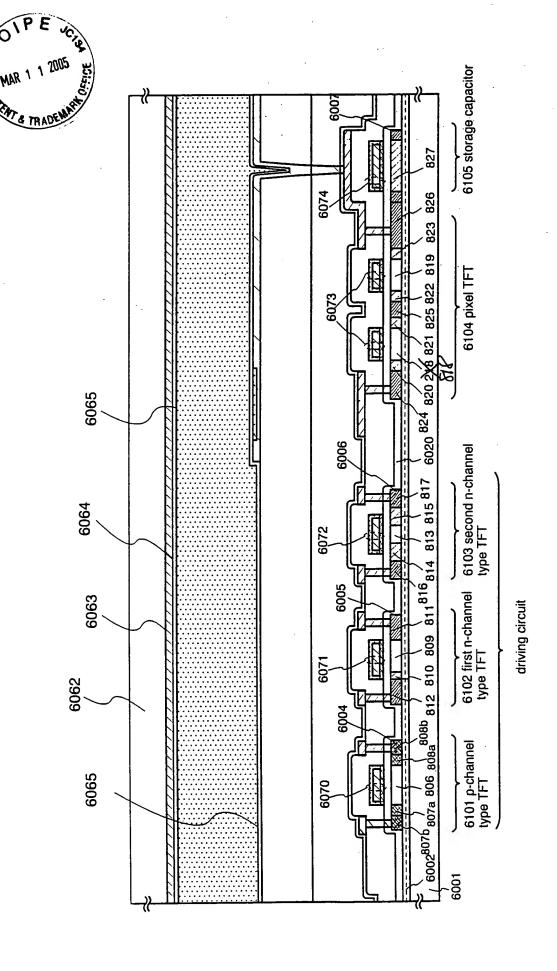
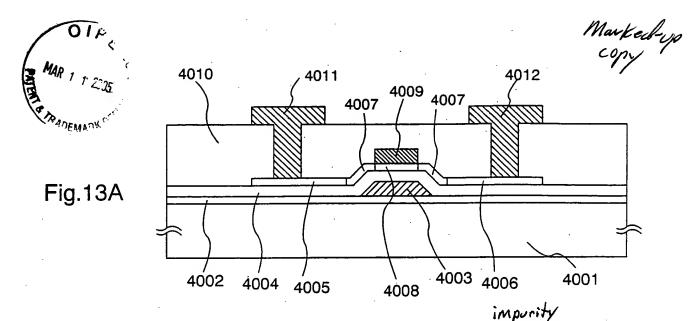


Fig.12



4001 substrate

4007 low concentration in stity region(LDD region)

4002 silicon oxide film

4008 channel forming region 4009 channel protective film

4003 gate electrode

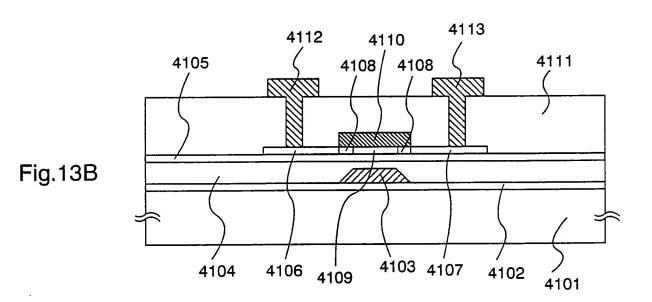
4004 gate insulating film 4010 interlayer insulating film

4005 source region

4011 source electrode

4006 drain region

4012 drain electrode



4101 substrate

4108 low concentration impurity region(LDD region)

4102 silicon oxide film

4109 channel forming region

4103 gate electrode

4110 channel protecting film

4104 bezocyclobutene(BCB) 4111 interlayer insulating film

4105 silicon nitride film

4112 source electrode

4106 source region

4113 drain electrode

4107 drain region